

**CLAIM AMENDMENT**

Please **CANCEL** claims 4-5 and 15-17, as follows.

Please **AMEND** claims 14 and 21, as follows.

Please **ADD** claims 22-26, as follows.

1-3. (Previously Withdrawn)

4-5. (Currently Cancelled)

6-13. (Previously Withdrawn)

14. (Currently Amended) A liquid crystal display, comprising:  
an insulating substrate;  
a gate wire formed on the substrate and comprising a gate line, a gate electrode and a gate  
pad, wherein the gate wire comprises a first main layer and a first supplementary layer;  
a gate insulating layer covering the gate wire;  
a semiconductor layer formed on said gate insulating layer;  
a data wire formed on the semiconductor layer comprising a data line, a source electrode  
and a drain electrode, wherein the data wire comprises a second main layer and a second  
supplementary layer made of one of either a metal or a metal alloy and formed on the gate  
insulating layer; a supplementary data wire located either on or under the entire data wire and  
made of either metal nitride or metal alloy nitride;

a passivation layer formed on the data wire and the gate wire and having a first contact hole extended to the gate pad and a second contact hole extended to the drain electrode or the supplementary data wire and covering said semiconductor layer; and

a transparent electrode conductive layer formed on the passivation layer and electrically connected to the gate pad through the first contact hole and the data wire through a the second contact hole formed in the passivation layer,

wherein the first supplemental layer and the second supplemental layer are substantially inert to an etchant used for etching the transparent layer for preventing the gate pad and the data wire from being eroded by the etchant.

15-17. (Currently Cancelled)

18-20. (Previously Withdrawn)

21. (Currently Amended) The liquid crystal display of claim 14, wherein the pixel electrode transparent conductive layer is made formed of indium tin oxide (ITO).

22. (Currently Added) The liquid crystal display of claim 21, wherein the transparent conductive layer comprises:

a gate ITO layer connected to the gate pad through the first contact hole; and  
a pixel electrode connected to the drain electrode through the second contact hole.

23. (Currently Added) The liquid crystal display of claim 14, wherein the first main layer and the second main layer comprise metal or a metal alloy.

24. (Currently Added) The liquid crystal display of claim 23, wherein the first supplementary layer and the second supplementary layer comprise metal nitride or metal alloy nitride.

25. (Currently Added) The liquid crystal display of claim 24, wherein the first supplementary layer and the second supplementary layer further comprise one selected a group consisting of tungsten, chromium, zirconium and nickel.

26. (Currently Added) A liquid crystal display, comprising:  
an insulating substrate;  
a gate wire formed on the substrate and comprising a gate line, a gate electrode and a gate pad, wherein the gate wire comprises a first main layer and a first supplementary layer;  
a gate insulating layer covering the gate wire;  
a semiconductor layer formed on said gate insulating layer;  
a data wire formed on the semiconductor layer comprising a data line, a source electrode and a drain electrode, wherein the data wire comprises a second main layer and a second supplementary layer;  
a passivation layer formed on the data wire and the gate wire and having a first contact hole extended to the gate pad and a second contact hole extended to the drain electrode; and

a transparent conductive layer formed on the passivation layer and connected to the gate pad through the first contact hole and the data wire through a the second contact hole, wherein the first main layer and the second main layer comprise metal or a metal alloy, and the first supplementary layer and the second supplementary layer comprise metal nitride or metal alloy nitride.